

# The Impact of Grounding on RF Performance

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**Johnstech International**



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The Johnstech logo consists of the word "Johnstech" in a white, bold, sans-serif font, centered within a solid red rectangular background.

## Agenda

- Theoretical background on grounding and its role in RF systems.
- Simulation setup and methodologies used to assess RF performance.
- Comparative analysis of various grounding locations and their impact on performance metrics.
- Case studies highlighting implementations

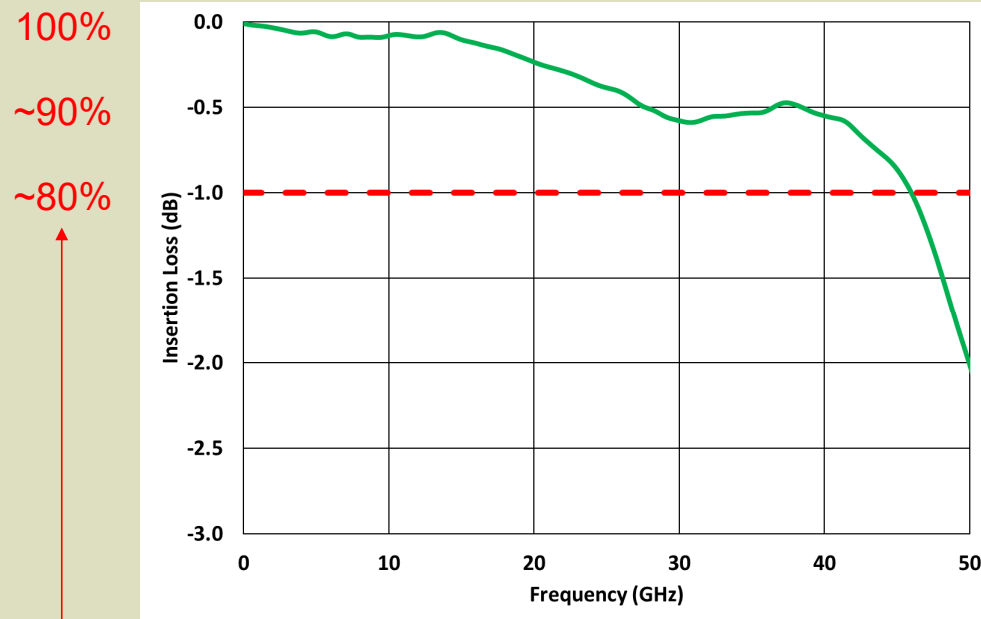


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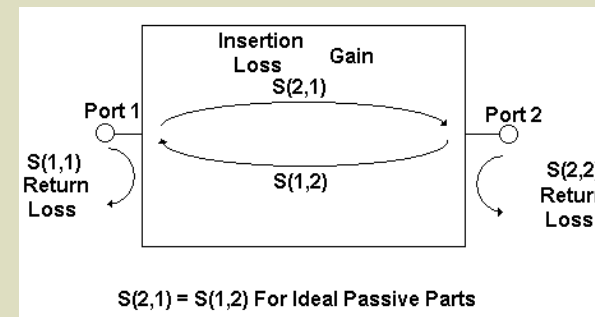
## Concepts: Insertion Loss



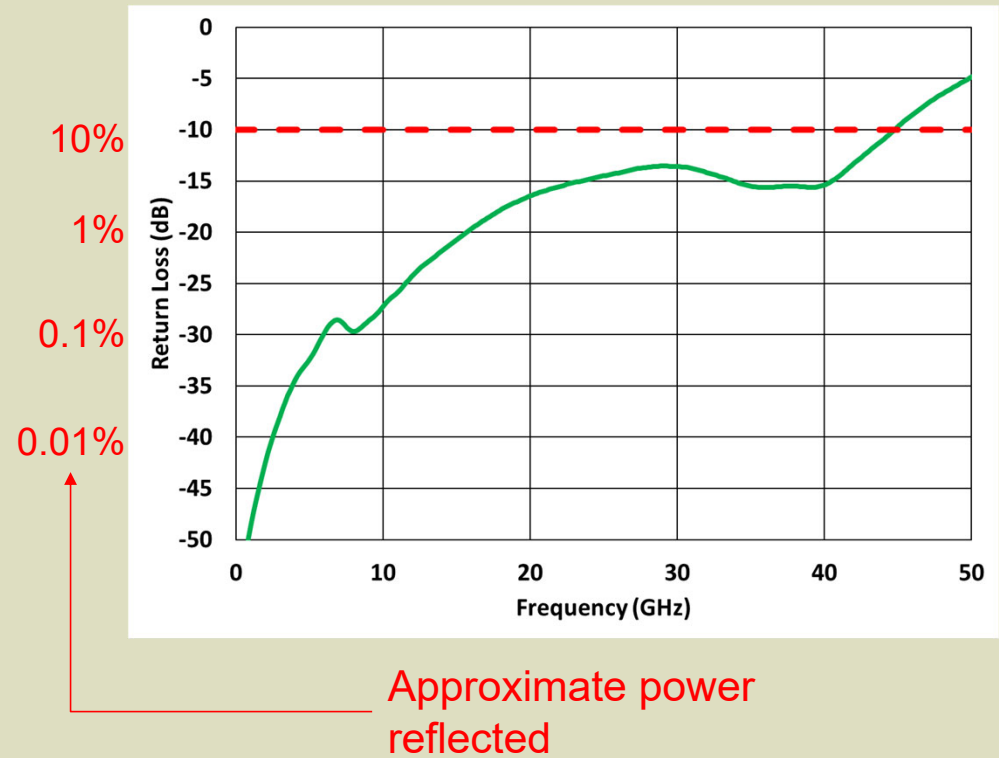
Approximate power transmitted

- Insertion Loss is the loss of signal power between two points in a circuit due to resistance, material absorption or impedance mismatch.

$$S_{21} = 10 * \log_{10}\left(\frac{P_{in}}{P_{out}}\right)$$



## Concepts: Return Loss



- Return Loss is the amount of power reflected back to a generator from a load due to impedance mismatch.

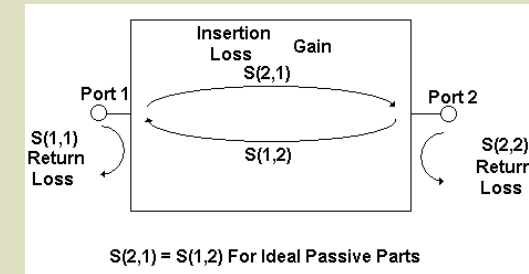
$$S_{11} = 10 * \log_{10} \left( \left| \frac{P_{reflected}}{P_{incident}} \right| \right)$$

or

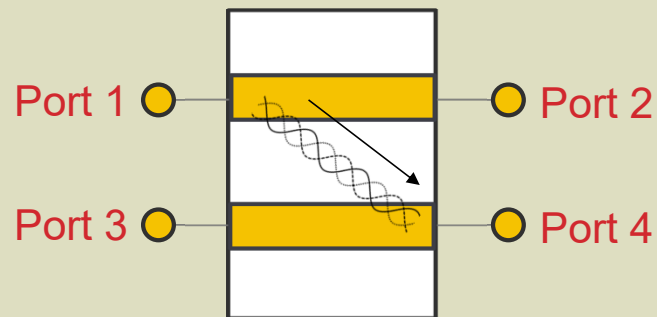
$$S_{11} = -20 * \log_{10} (|\Gamma|)$$

where

$$\Gamma = \frac{(Z_L - Z_0)}{(Z_L + Z_0)}$$



## Concepts: Crosstalk



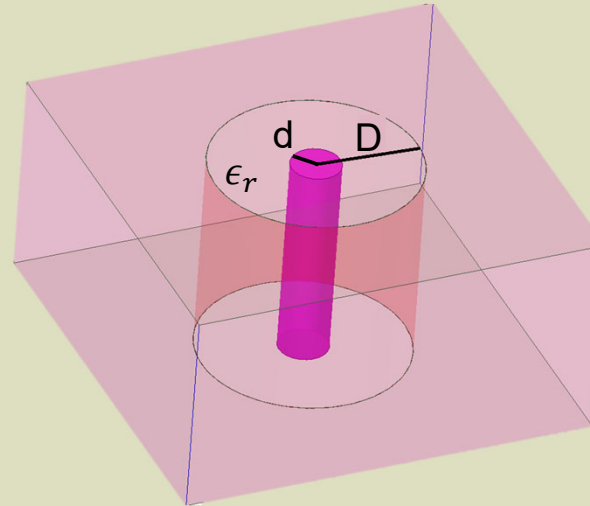
- Crosstalk is the coupling of undesired signals between lines.
- $S_{41} = 10 * \log_{10} \left( \frac{P_4}{P_1} \right)$ 
  - $P_1$  is the input power at Port 1
  - $P_4$  is the power received at Port 4 from Port 1

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## Theoretical Coax: Effects of Ground Location – Distance to Ground

Coaxial Impedance

$$Z_0 = \frac{138}{\sqrt{\epsilon_r}} \log_{10} \left( \frac{D}{d} \right)$$



D	Z <sub>0</sub>
1.000mm	85.2 Ω
0.750mm	68 Ω
0.556mm	50.2 Ω
0.500mm	43.9 Ω
0.400mm	30.5 Ω

Where:

Z<sub>0</sub> = characteristic impedance of the coax (Ω)

ε<sub>r</sub> = relative permittivity (dielectric constant) of the insulator

D = inner diameter of the outer conductor (m)

d = outer diameter of the inner conductor (m)

Note: d = 0.24mm

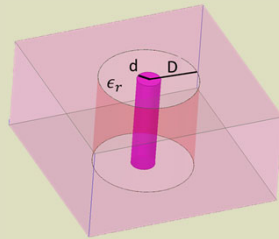
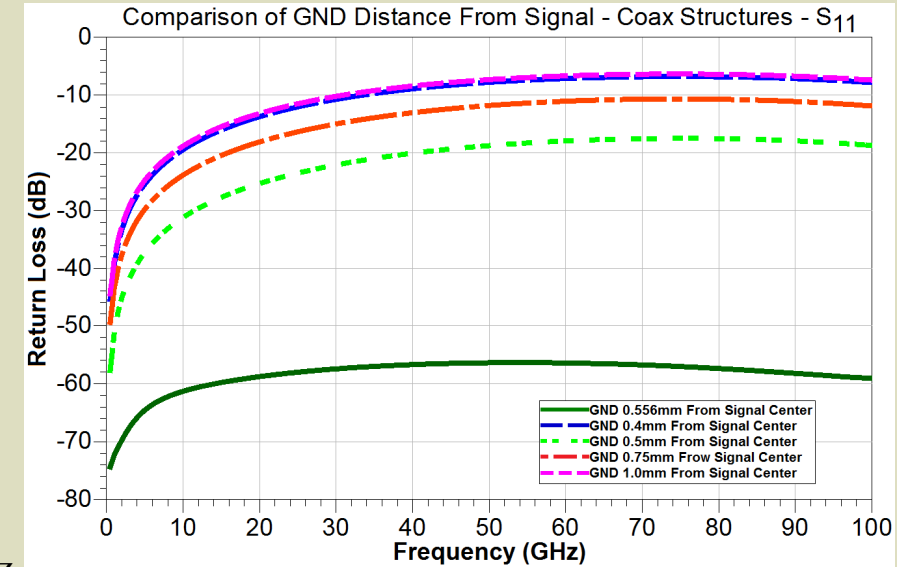
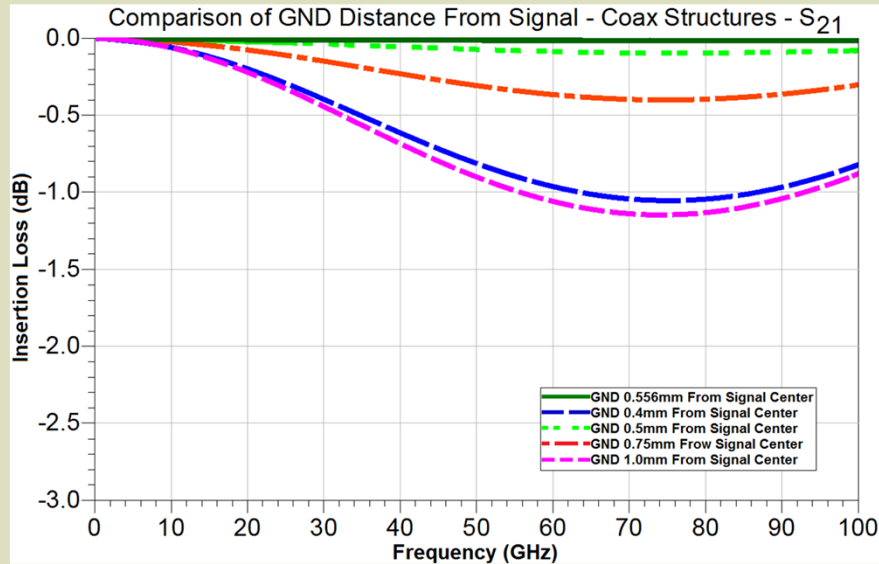


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## Theoretical Coax: Effects of Ground Location – Distance to Ground



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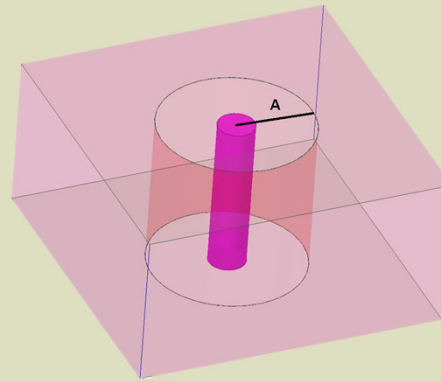
Deviation from 50 Ohms leads to lower return loss (more reflections)



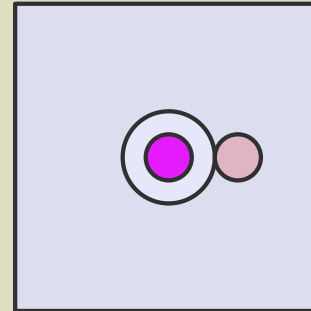
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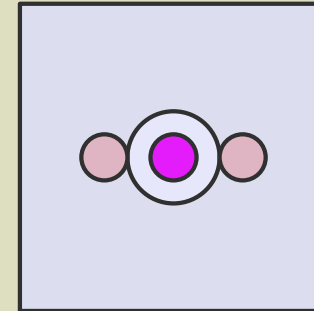
## Theoretical Coax: Effects of Ground Location Number of Grounds



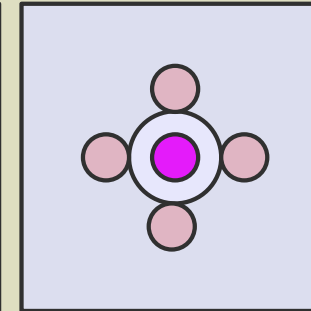
Coax



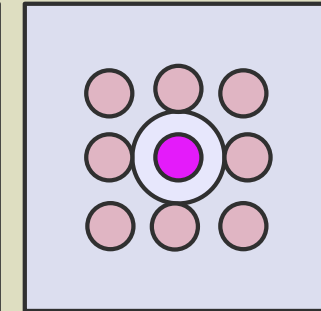
1 Ground



2 Grounds



4 Grounds



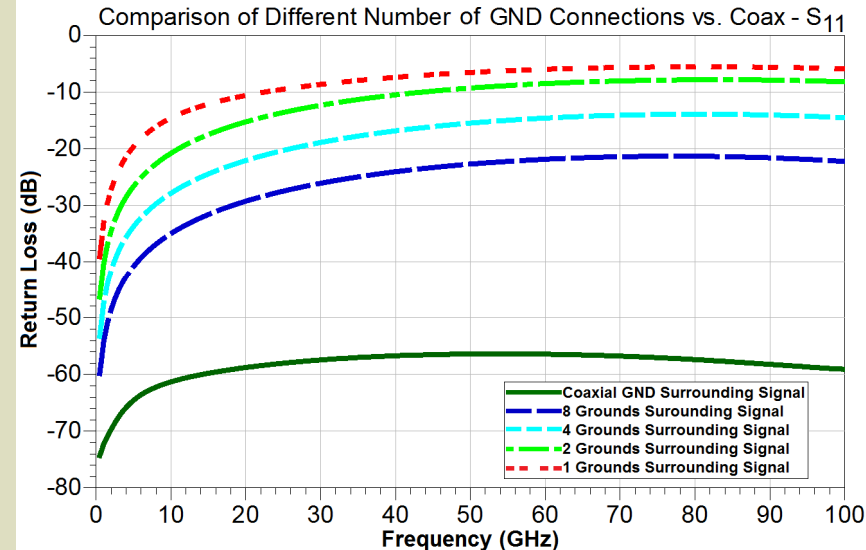
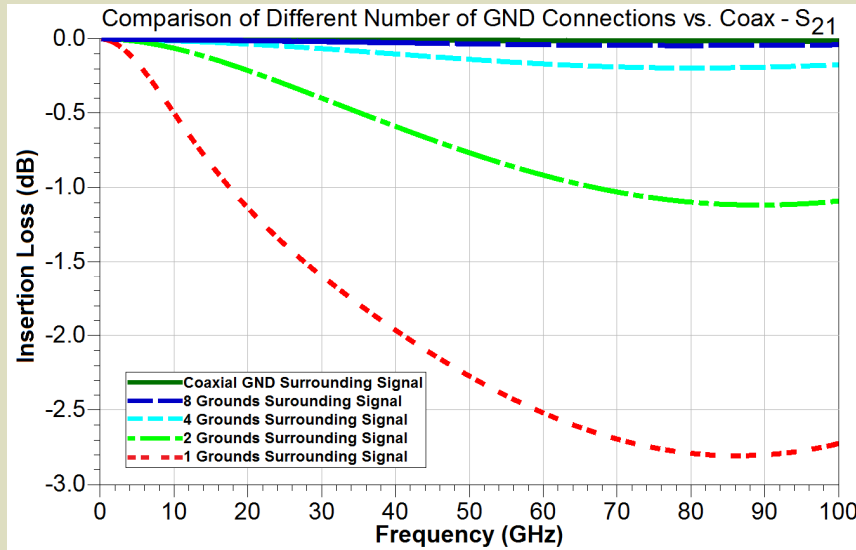
8 Grounds

Continuous ground coax is ideal and when not possible, need to bring grounds very close.

How many are required?



## Theoretical Coax: Effects of Ground Location Number of Grounds



Grounds	Z <sub>0</sub>
1	81.8 Ω
2	66.2 Ω
4	56.9 Ω
8	52.9 Ω
Coax	50.2 Ω



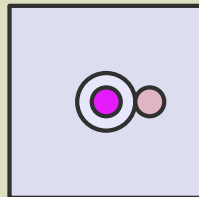
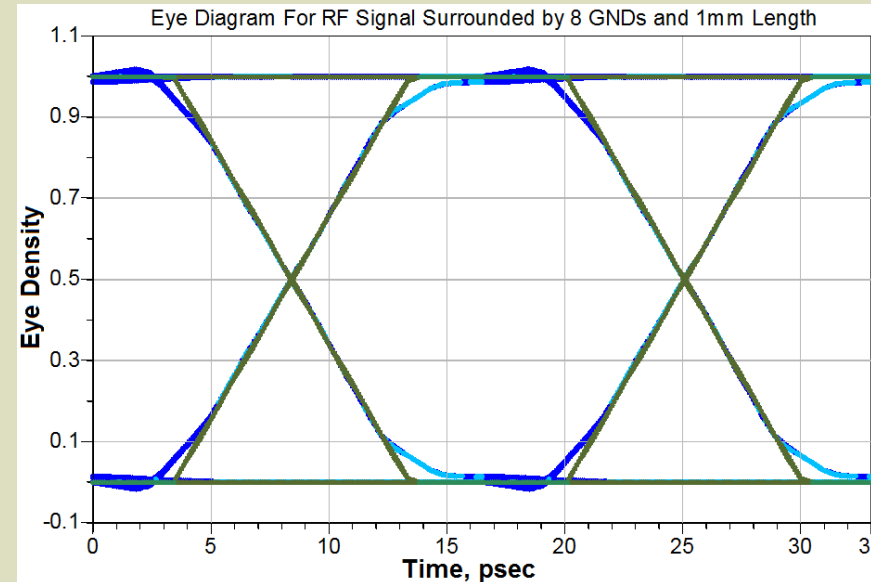
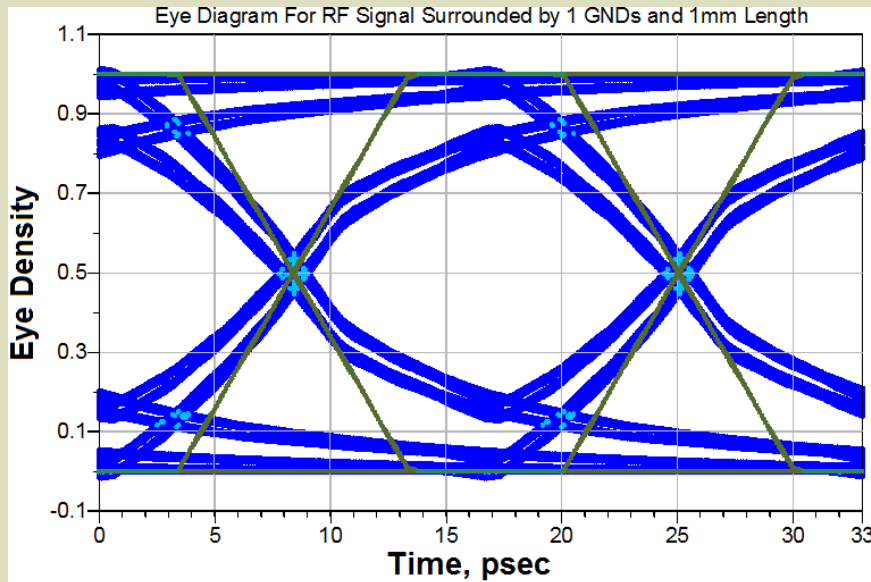
Addition of grounds brings the system closer to ideal coax of 50 Ohms



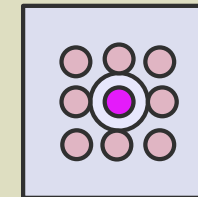
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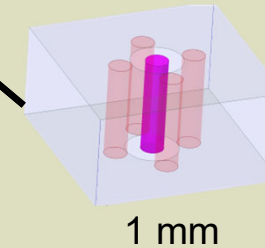
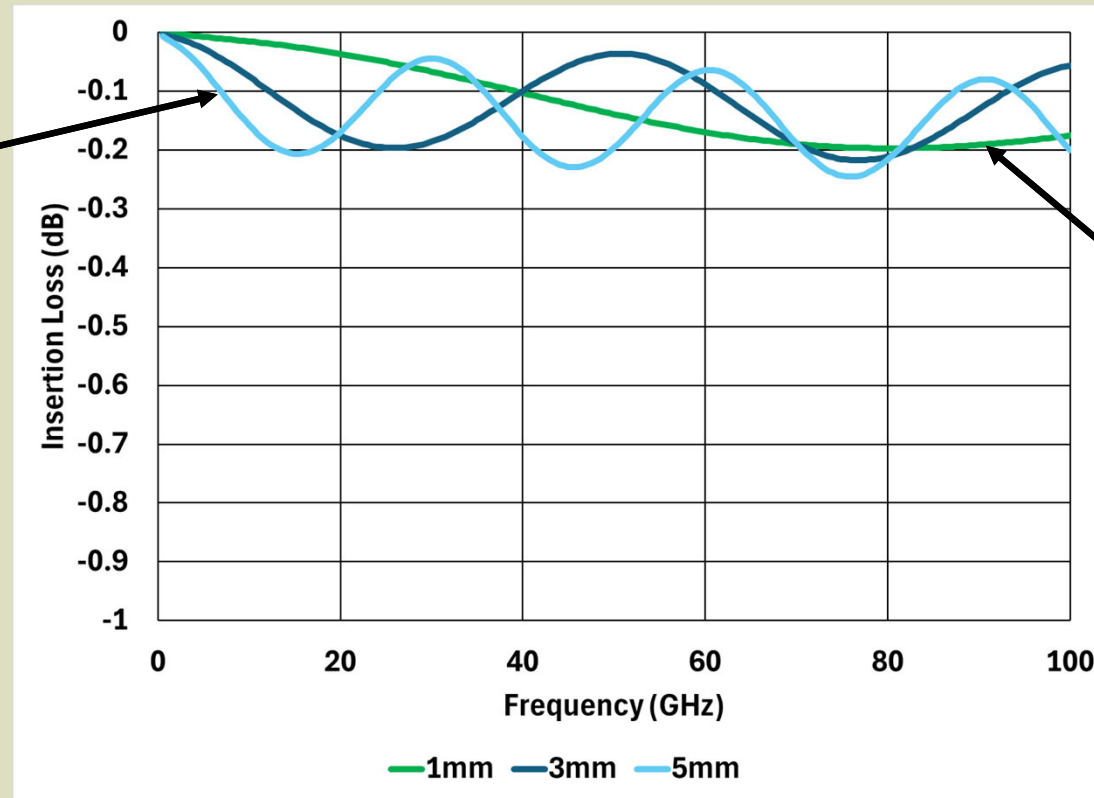
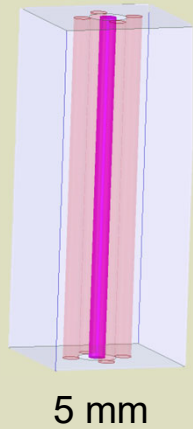
## Theoretical Coax: Effects of Ground Locations Time Domain



Eye Diagram @ 60 Gbps

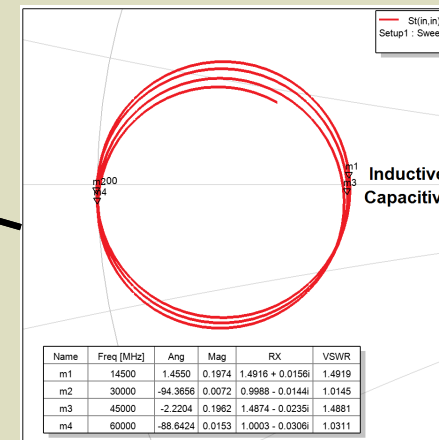
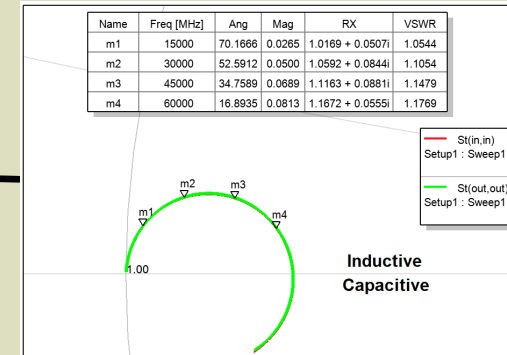
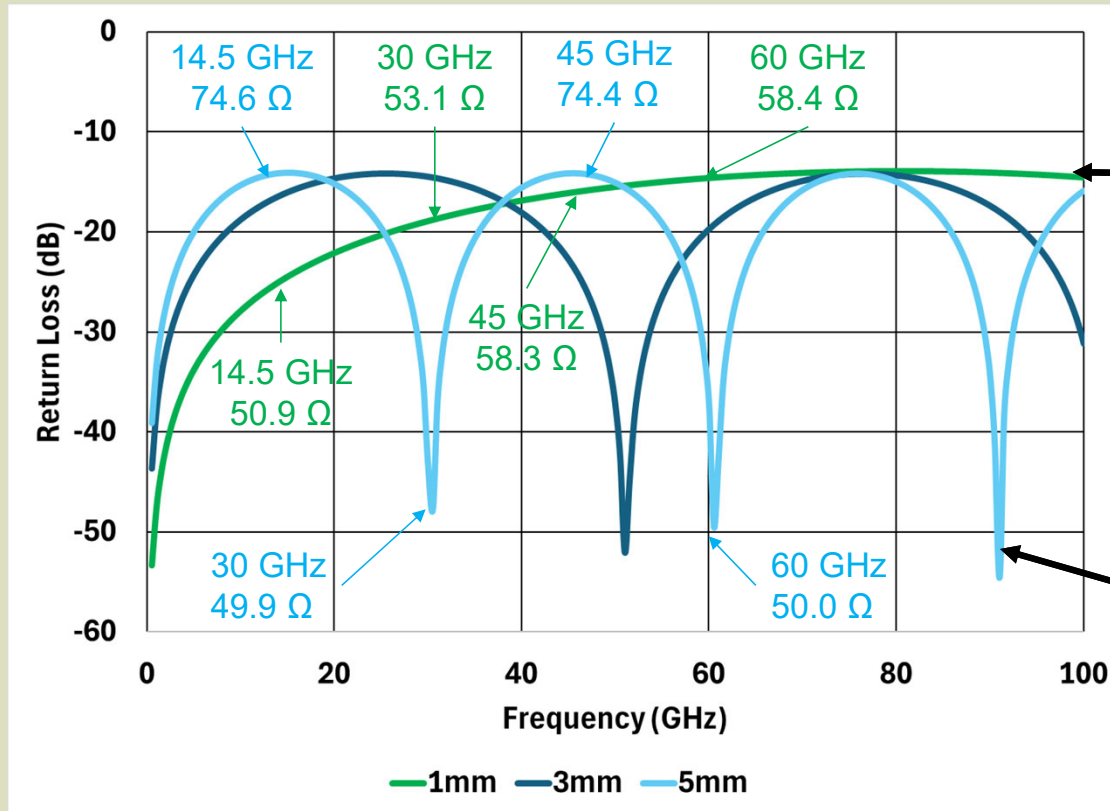


## Theoretical Coax: Different Contact Heights



Why does the Insertion Loss improve at various frequencies?

## Theoretical Coax: Different Contact Heights

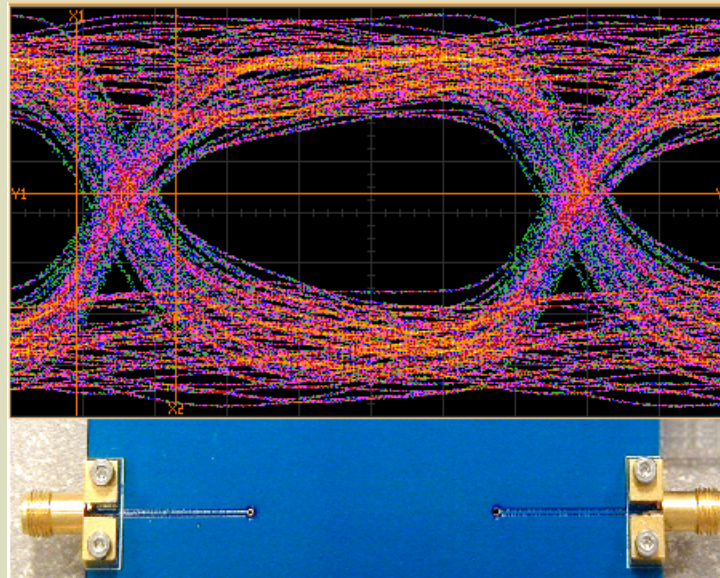


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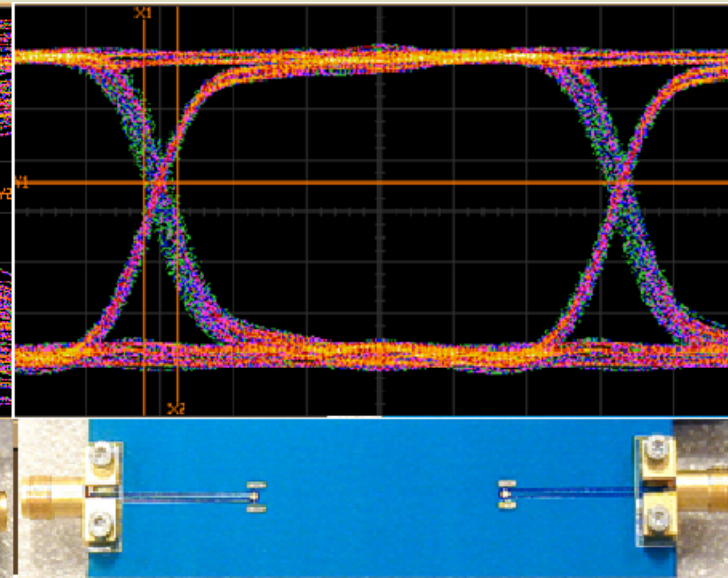
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## Proper grounding produces clean signals

Vias not shielded by ground



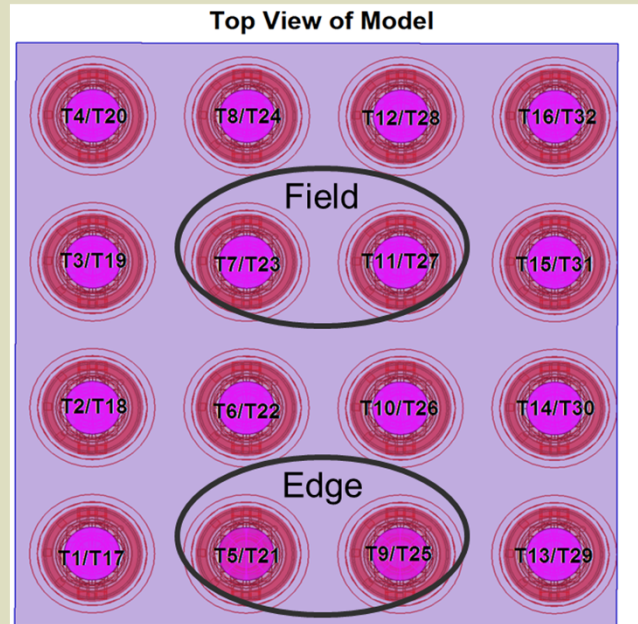
Vias surrounded by ground



Vias attach ground planes and significantly improves signal integrity

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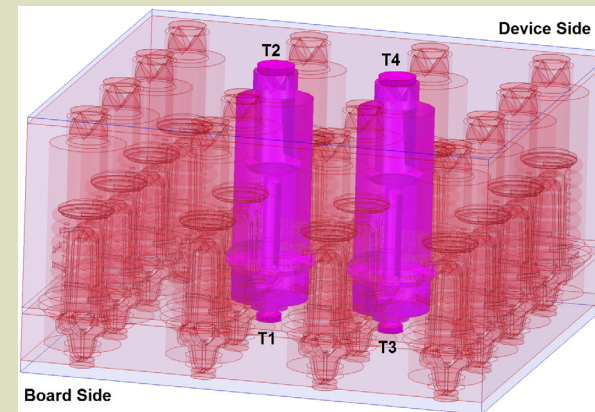
## Example: 1 mm Probe\* @ 0.5 mm Pitch Different Ground Configurations



First terminal listed is board side terminal and second terminal listed is output and device interface

Application: PAM4 112 Gbps high speed bus.

Challenge: Multiple configurations within the device needed to be evaluated to ensure high speed performance.



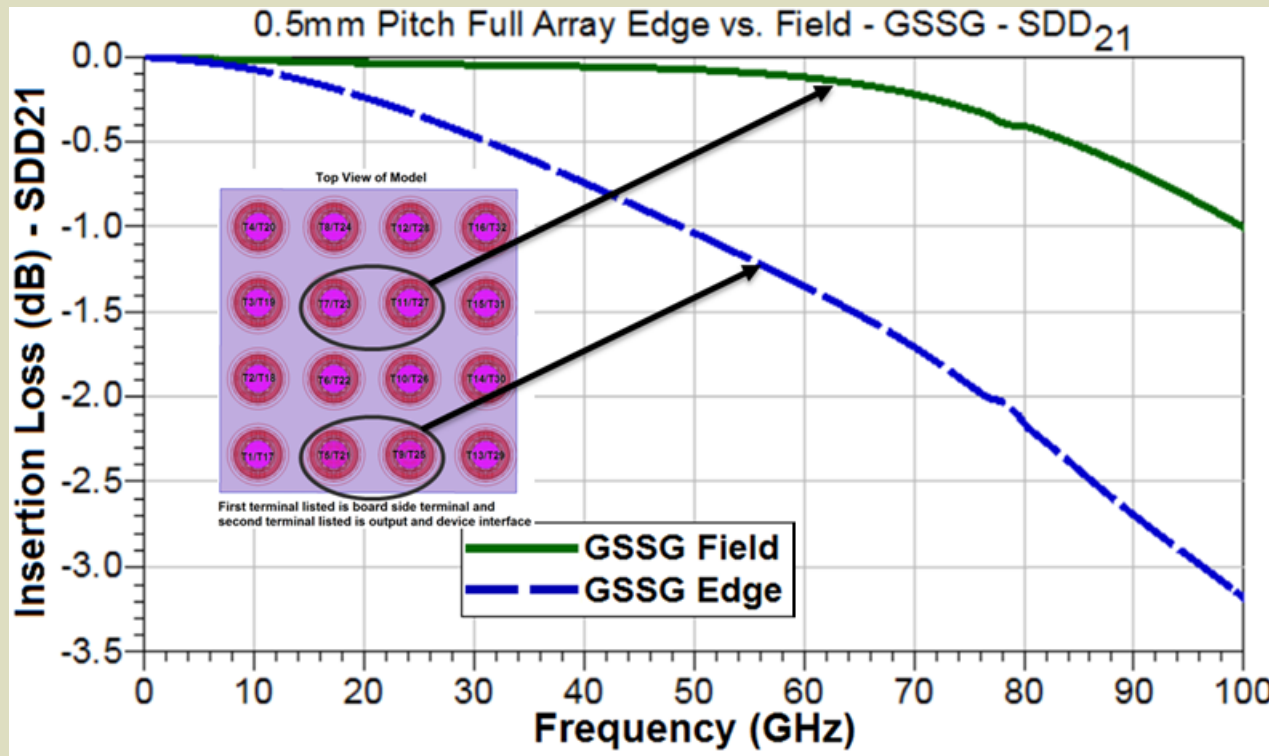
\* Probe test height = 1 mm





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## Example: 1 mm Probe @ 0.5 mm Pitch Different Ground Configurations



Field configuration in differential mode performance up to 100 GHz.

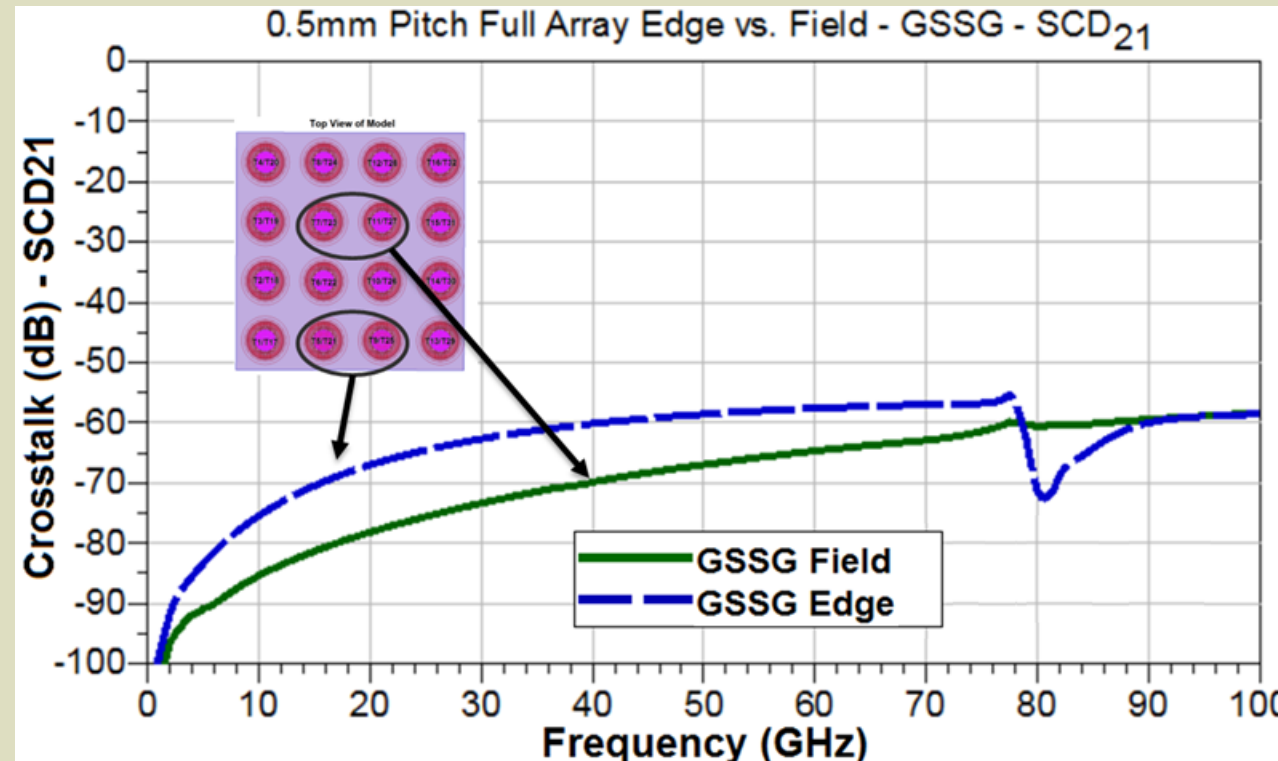
Short probe technology allows for 50 GHz performance in edge configuration.

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## Example: 1 mm Probe @ 0.5 mm Pitch Different Ground Configurations

Excellent isolation performance in either field or edge configuration.

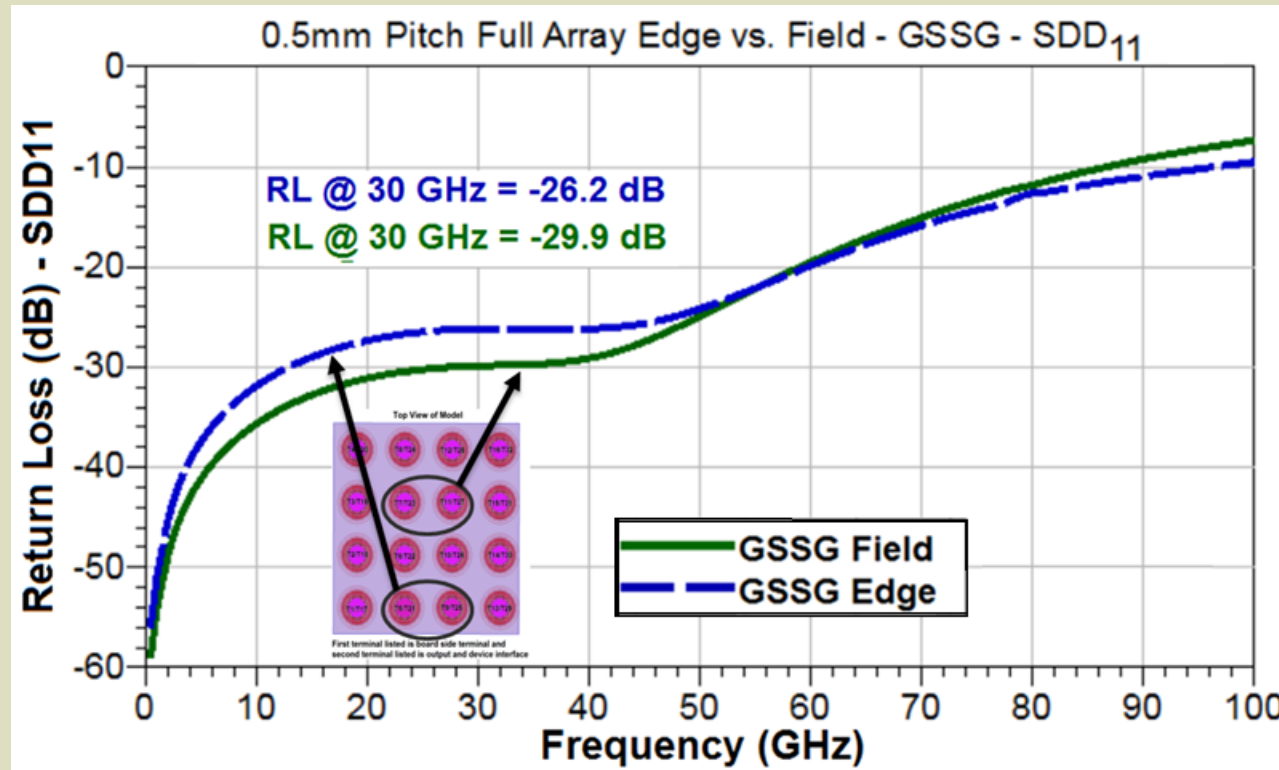
The addition of grounding minimizes the noise on the differential pairs, reducing the signal loss associated with crosstalk.





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## Example: 1 mm Probe @ 0.5 mm Pitch Different Ground Configurations



At 30 GHz, what accounts to additional reflected power in the Edge configuration?

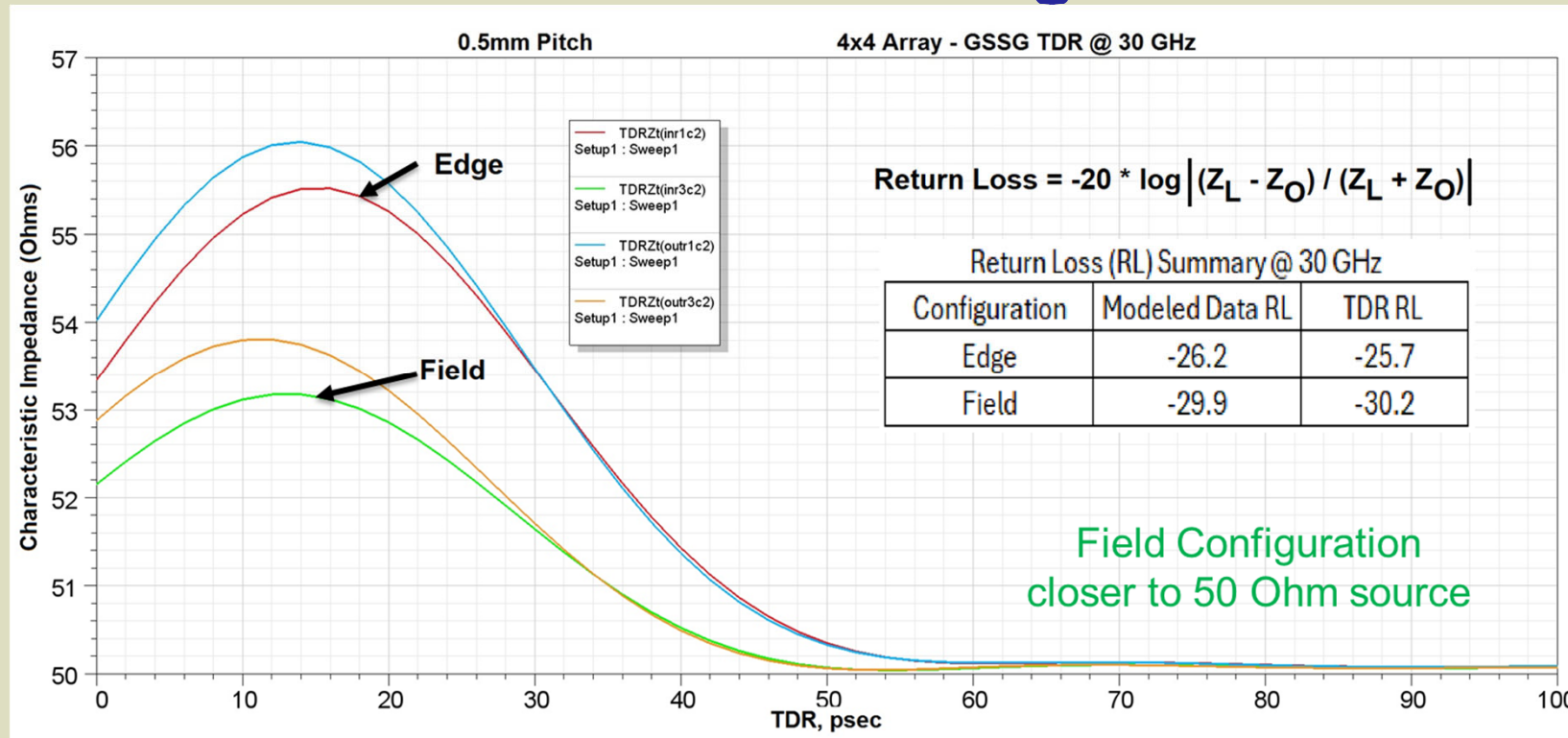
Field

0.1% power reflected

Edge

0.25% power reflected

## Example: 1 mm Probe @ 0.5 mm Pitch Different Ground Configurations



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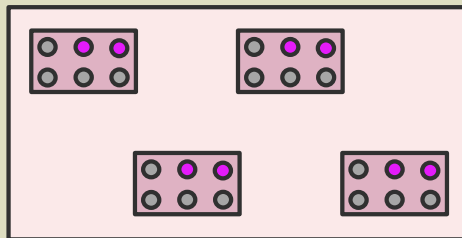
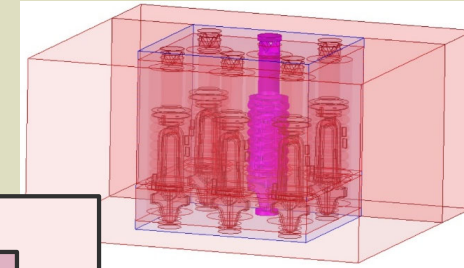
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## Example: 1 mm Probe WLCSP Array Comparison Of Metal vs. Optimized Housing

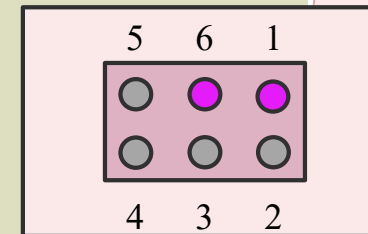
Application: High power RF switch requiring excellent isolation (very low crosstalk on pins 6 to 1)

Challenge: Due to geometry constraints, providing full ground surrounding each test site may not be possible. Need to determine how grounding impacts isolation.

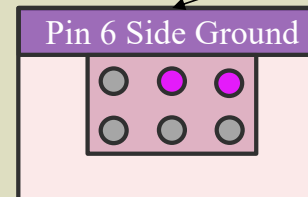


Ground

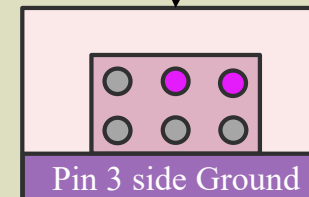
● RF Pins  
● Other



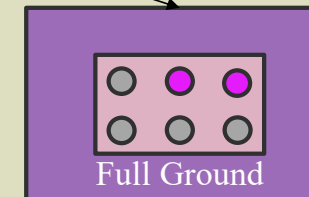
No perimeter ground



Pin 6 Side Ground



Pin 3 side Ground



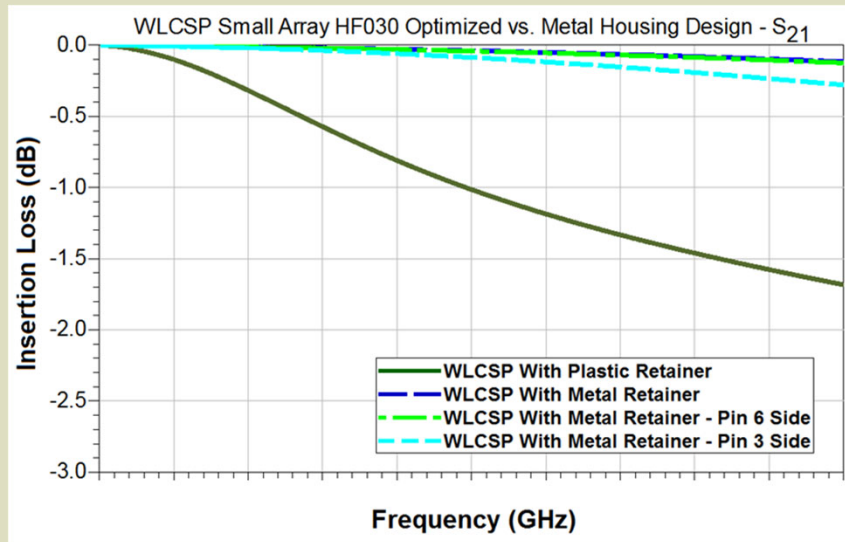
Full Ground



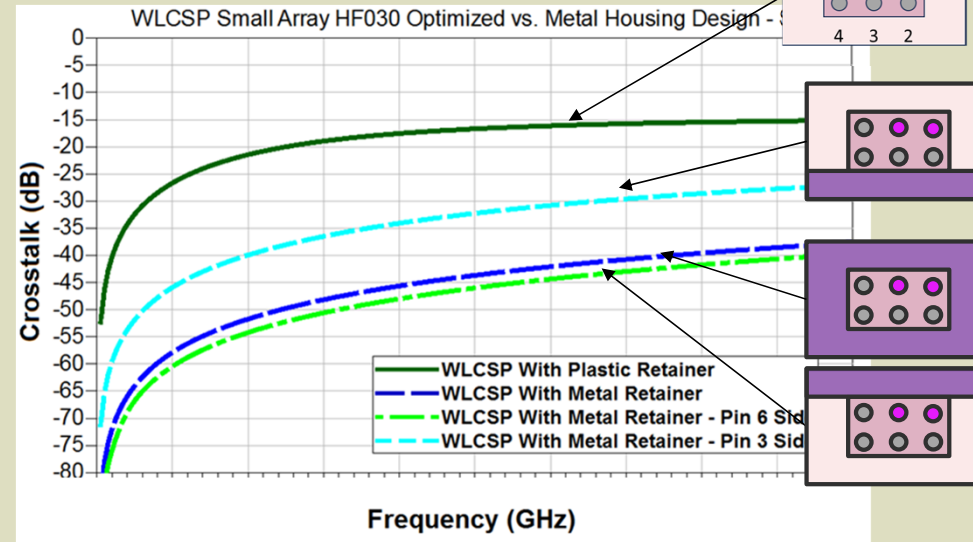
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## Example: 1mm Probe WLCSP Array Comparison Of Metal vs. Optimized Housing



The addition of any ground improves Insertion Loss



Improved isolation with grounding in proximity to signal pins



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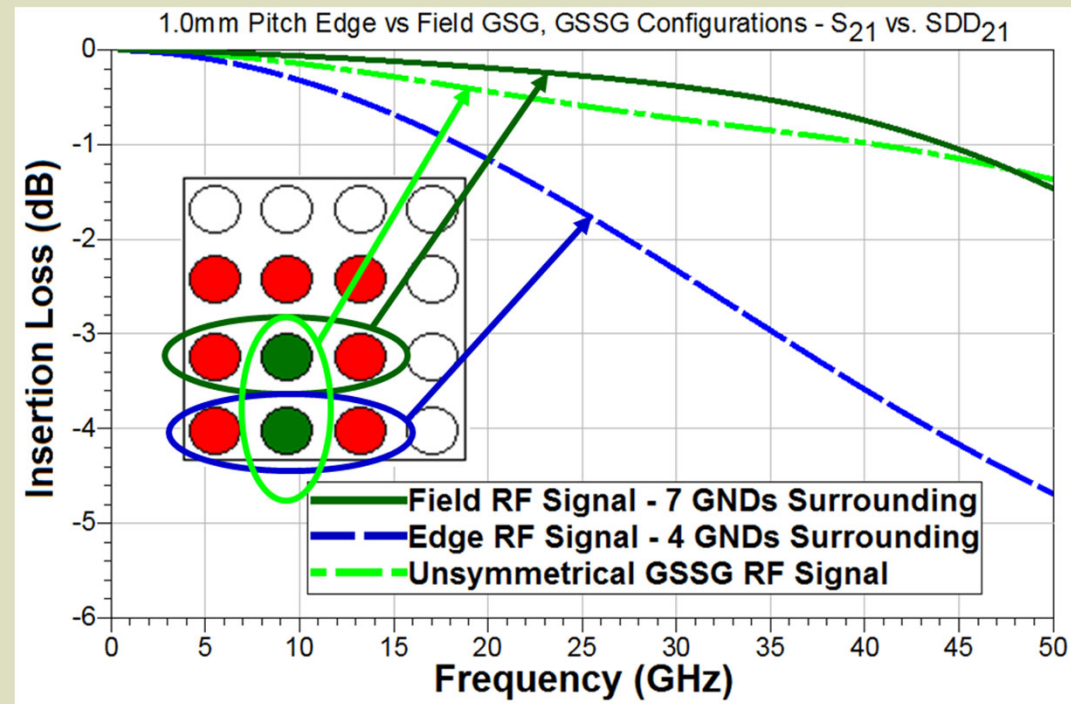
## Example: 1 mm Probe @ 1.0 mm Pitch Crosstalk and Symmetry

Challenge: Larger pitches have grounds farther away which tends to increase characteristic impedance. Additionally, non-symmetrical configurations impact crosstalk.

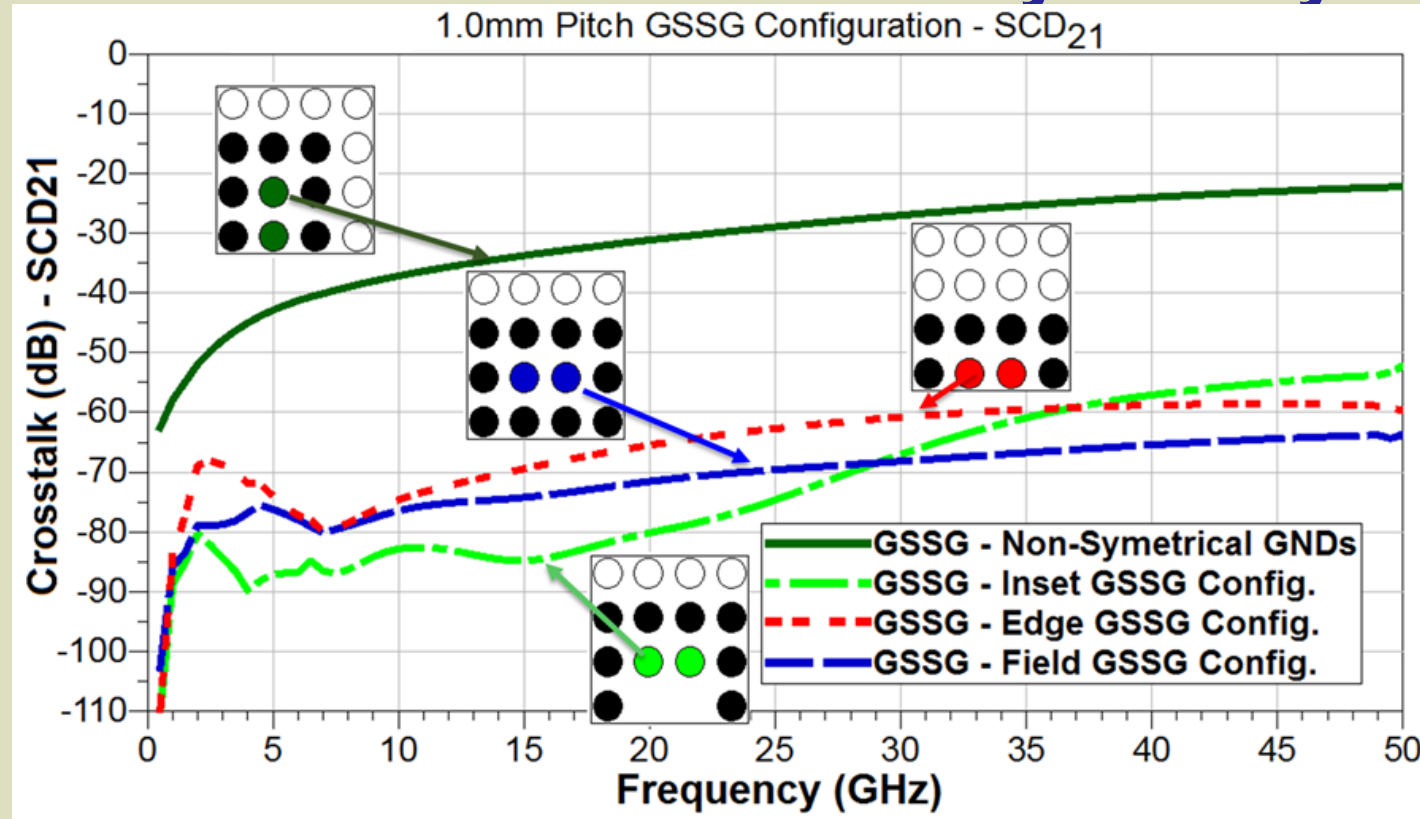
$$Z_0 \propto \log_{10} \left( \frac{D}{d} \right)$$

pitch

probe Ø



## Example: 1 mm Probe @ 1.0 mm Pitch Crosstalk and Symmetry



Non-symmetric

Symmetric

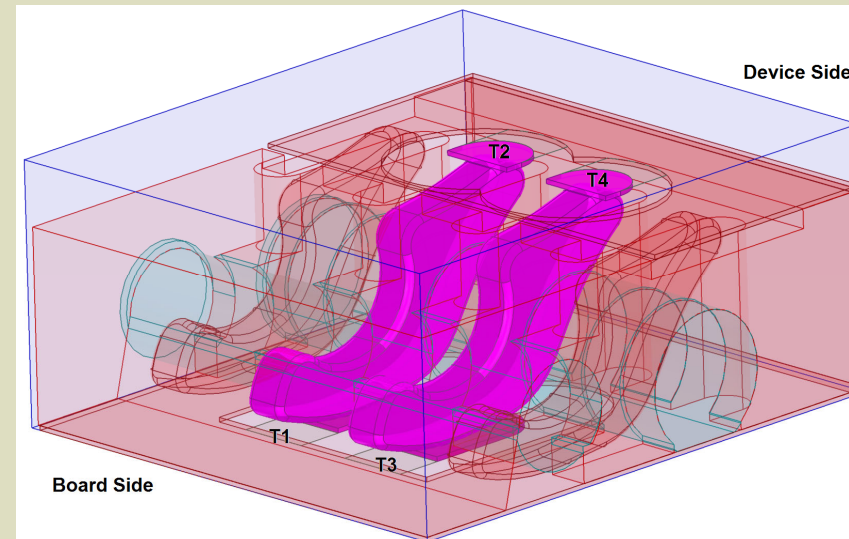
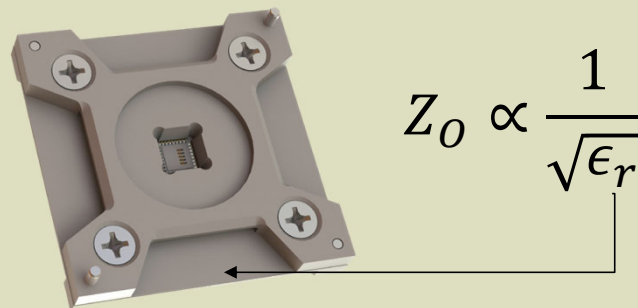
Ground Symmetry is impactful



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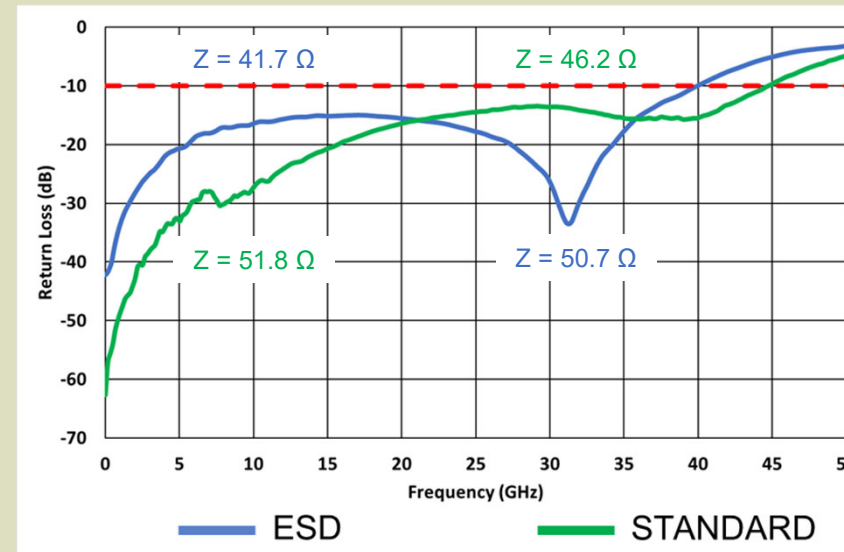
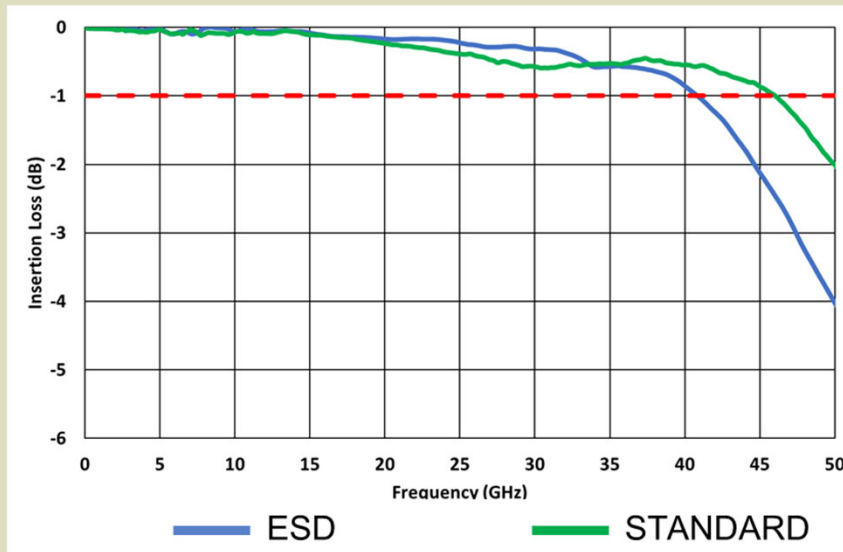
## Example: Solid Contact Technology Impact of Dielectric on RF Performance

- Application: ESD-sensitive devices
- Challenge: Developed solid contact technology with standard materials. Customers requesting static dissipative materials that limit triboelectric charging to <100V. Need to determine the impact of performance over frequency.



## Example: Solid Contact Technology Impact of Dielectric on RF Performance

$$Z_0 \propto \frac{1}{\sqrt{\epsilon_r}}$$

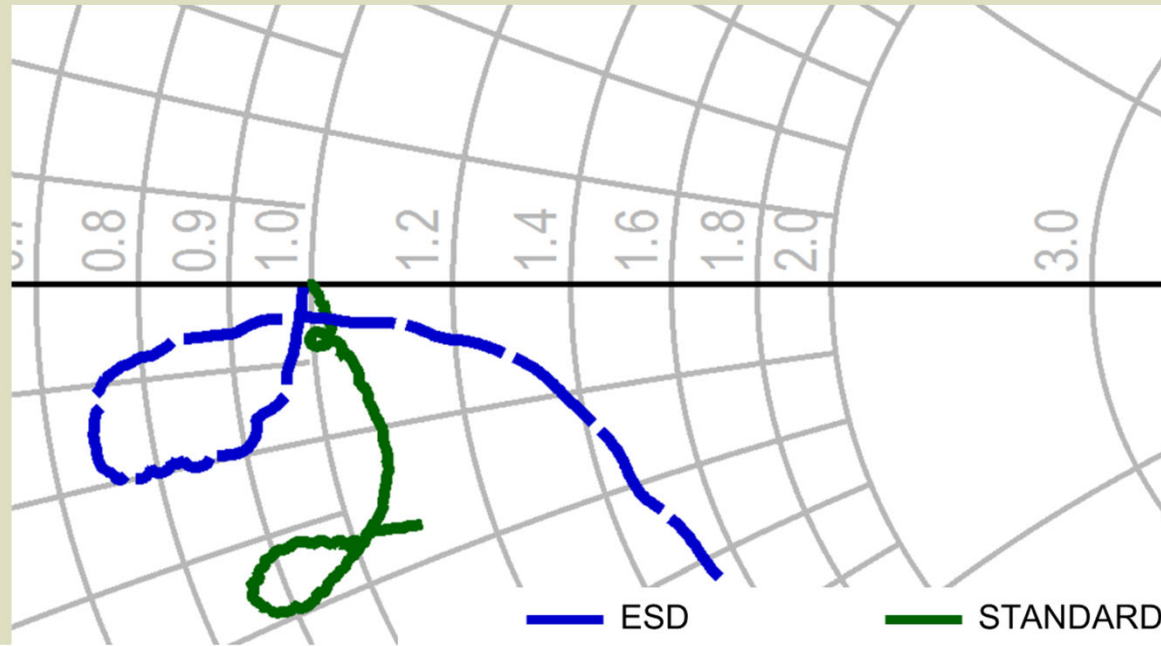


ESD material has a higher dielectric, which lowers the impedance from 50 Ohms





## Example: Solid Contact Technology Impact of Dielectric on RF Performance



Housing Material	10 GHz Imp.	20 GHz Imp.	33 GHz Imp.	10 GHz RL	20 GHz RL	33 GHz RL
Standard	51.8 - j4	52.4 - j15.5	43.8 - j16.7	-27.3	-16.4	-14.5
ESD	40.5 - j9.9	37.2 - j7.1	55.8 - j2.8	-16.4	-15.5	-24.4

## In Summary

- Many variables in socket design impact signal integrity
  - Signal/grounding configuration, material, contact design
- Impact can be seen when comparing simulations of
  - Insertion loss, return loss, impedance, crosstalk
- The quality of the ground has a major influence on signal integrity
  - Number of grounds
  - Proximity to grounds
  - Symmetry of grounds
  - Signal configuration (GSG, GSSG)
- Impacts of above variables are application specific and must be considered for each unique package layout



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